

S & S T E C H

Investment Relations

Y2024 Q1

S&STECH

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- The “Forecast Information” included in this material is information that has not gone through a separate verification process. It pertains to the future management and financial performance that is expected by the company, rather than the past.
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01 . Company Overview

Company Name	S&S Tech Corporation
CEO	Jeong, Soo Hong (Largest Shareholder)
Founded	February 22nd, 2001
Location	Daegu, South Korea
Members	290 (As of 2024.01)
Business	Blank Mask for Semiconductors and FPD
Customers	Samsung Electronics, Samsung Display, SK Hynix, Super Mask, Newway, + 25 in domestic & global
Patents	208 Listed (Domestic 106 / International 102)



<S&S Tech Headquarter in Daegu>

01 . S&S Tech History

Our company is a **leading professional enterprise**, achieving sustainable growth through continuous technological innovation and securing market competitiveness, as well as **contributing to the nation and local communities**.

2001 ~ 2004

1. Market Entry

- Establishment
- First development of Binary Masks in Korea
- Quality Certification – SEC
- Binary Mask Export
- ISO9001 Certification

01 . S&S Tech History

2005 ~ 2008

2. Foundation of Growth

- FPD Blank Mask Development and Production
- USD \$10M Export
- Newtech Award from the President
- Appointed as Korea's Top 10 New Tech

2009 ~ 2014

3. Sustainable Growth

- High-End Market Entry
- PSM Development
- PSM Export to Taiwan
- IPO in 2009 (KOSDAQ)
- USD \$20M export
- 2014 World Class 300

2016 ~

4. Current and Future

- "High – Tech Company" Certification
- 2016 New Factory Establishment
- SEC Investment (Capital Increase, \$49M)

02. Blank Mask Introduction

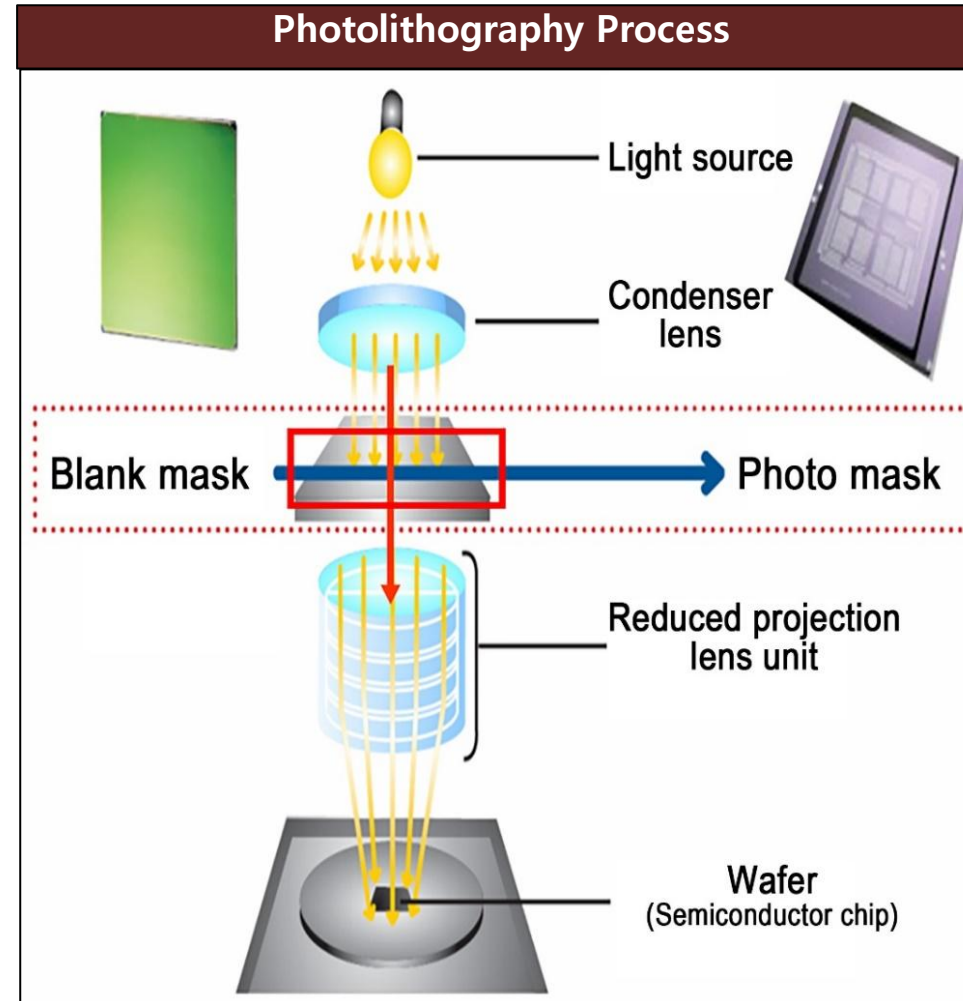
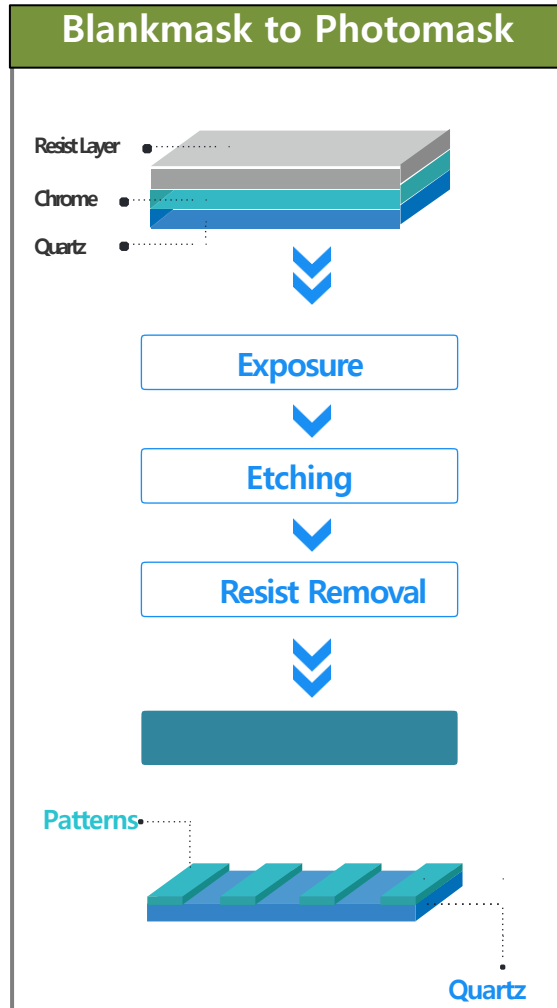
Blank Mask ,

✓ Blank masks for **semiconductors** are used as raw material for photomasks, which typically have a pattern of several hundreds to several tens of nanometers in size, for high integration of circuits within a limited size, such as DRAM. Important factors for resolution improvement include substrate, metal film and resist film properties. In addition, due to the demand of small pattern size, a highly strict specification is required to minimize defects such as particles

✓ Blank mask for **FPD** is raw material for manufacture of liquid crystal display devices such as TFT-LCD, and unlike blank masks for semiconductors with standard and limited size variations, blank masks for display have a extensive range of sizes pending on the final product. FPD blank masks are referred to as large blank masks due to their relatively larger size. Using photomasks processed from these FPD blankmasks, various types of display panels can be manufactured including smartphones, table PCs, computer monitors, and TVs.



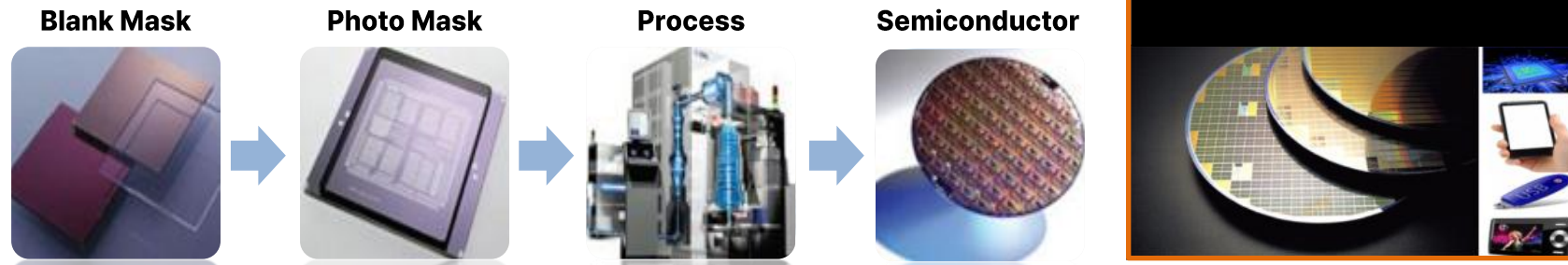
02. Blank Mask Introduction



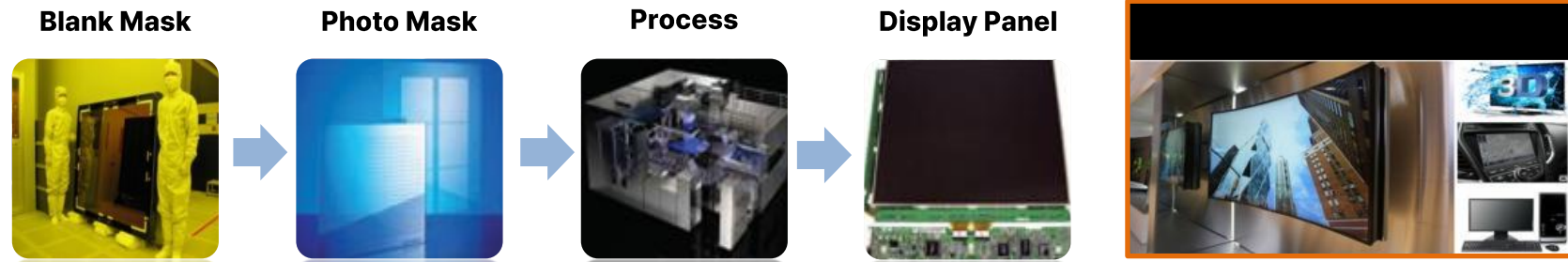
02. Product Application

✓ Blank mask is the main raw material for photo masks and can be applied to semiconductors and display (TFT-LCD, OLED, LED)

Semiconductor Blank Mask



Display Blank Mask



02. Supply Chain Overview

Semiconductor		Display
<p>Samsung Electronics, SK Hynix SMIC, Hua Hong, CXMT TSMC, UMC Intel</p>	<p>End User</p>	<p>Samsung Display, LG Display BOE, CSOT</p>
<p>Photronics Toppan, DNP</p>	<p>Photo Mask</p>	<p>Hoya, DNP, SKE Photronics Ever Rich, Newway</p>
<p>Hoya, ShinEtsu, Ulcoat</p> <p>S&STECH</p>	<p>Blank Mask</p>	<p>Ulcoat, CST, Hoya</p> <p>S&STECH</p>
<p>ShinEtsu AGC</p>	<p>Quartz</p>	<p>ShinEtsu KTG</p>

03. Market & Industry Overview

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Strategic response to the rising Chinese semiconductor market

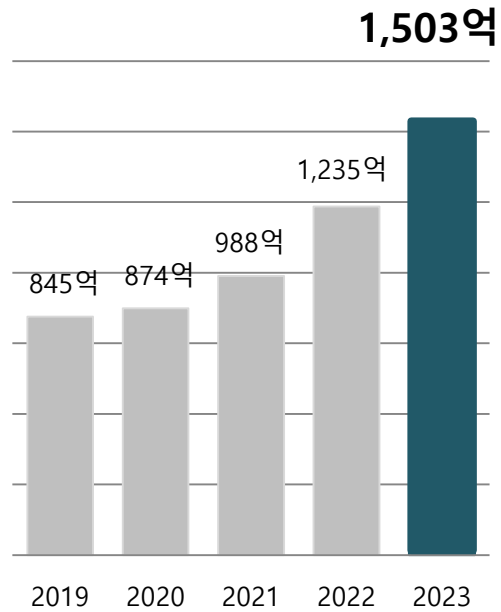
M a r k e t

Stability and steady growth in both domestic and international display industries

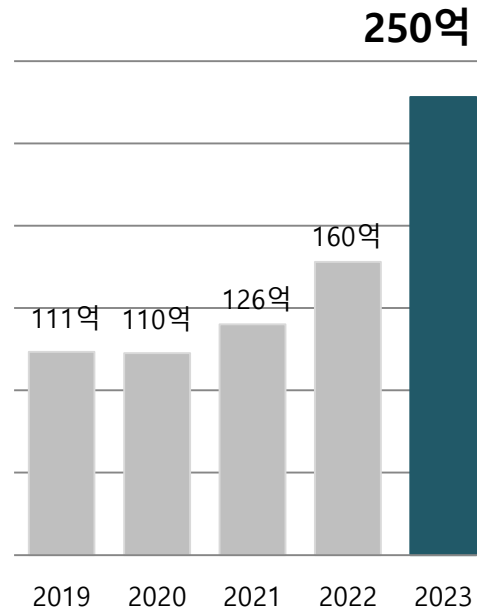
P r o s p e c t

Envisioning entry into the EUV market

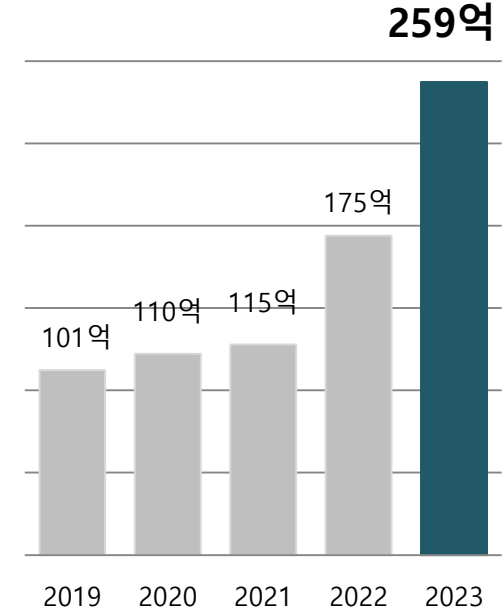
04. Financial Summary (Consolidated) (YoY)



Sales



Operating Profit



Net Profit

Thank you.

EOD